A simple, low-cost CVD route to high quality CH₃NH₃PbI₃ perovskite thin films

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Fig. S1 Photograph showing large-area uniform CH₃NH₃PbI₃ film grown by sequential AACVD on FTO glass substrate.

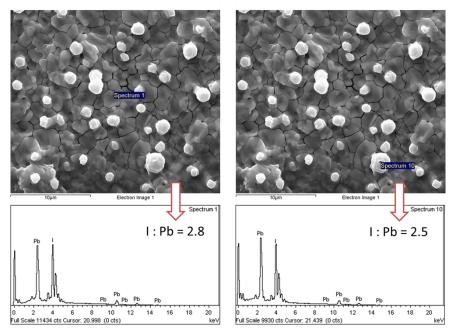


Fig. S2 SEM image and corresponding EDS spectra of AACVD CH₃NH₃PbI₃ film on FTO glass.

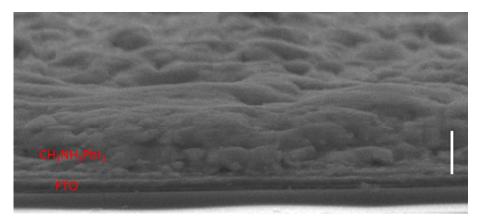


Fig. S3 Cross-section SEM image of AACVD $CH_3NH_3PbI_3$ film on FTO glass. The error bar corresponds to $1.5~\mu m.$